Lecture 4:

2008 Term Project Review

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Project Goals & Design Constraints

- Design and Fabricate of the x/y dual-axis comb-drive resonator
 - 1st order natural frequency: 4 kHz ~ 6 kHz
 - 2nd order natural frequency: about 0.45 kHz \sim 0.55 kHz than 1st order natural frequency
 - Accuracy of frequency is most important
 - Large displacement & Low voltage also necessary
- **Design Constraints**
 - Chip size: 4 mm x 4 mm
 - Lithography, etch constraints: minimum dimension (4 um CD)
 - Primary mode natural frequency: 5 kHz
 - Secondary mode natural frequency: 5 kHz + 500 Hz (± 10 %)
 - Actuation voltage: The lower, the better

Project summary

Calculated result

	#			1	2	3	4	!	5	6	7	8	9	10	
	type		#1	#2	#1	#1	#1	#1	#2	#1	#1	#1	#1	#1	
	type		serpentine	serpentine	serpentine	guided end	folded	serpentine	serpentine	serpentine	guided end	guided end	guided end	serpentine	
	number	x-axis	4	4	12	8	4	4	4	4	8	8	6	8	
spring	of spring	y-axis	4	4	12	8	4	4	4	4	4	8	8	6	0
design	spring	x-axis [N/m]	152.3	-	105.7	196.0	130.3	21.6	21.6	34.5	37.0	95.3	56.1	8.4	
	constant	y-axis [N/m]	193.2	-	127.0	256.0	140.8	26.8	26.8	38.5	43.5	115.4	68.1	10.2	
mass design		ass (g]	6.06E-07	-	9.90E-08	2.07E-07	1.28E-07	8.81E-08	9.81E-08	1.33E-07	3.52E-08	9.66E-08	3.72E-07	6.81E-08	
1st mode frequency	[۱	Hz]	5047	-	5200	4897	5070	4984	4723	5127	5160	4999	4784	5000	
2nd mode frequency	[Hz]	5684	-	5700	5597	5340	5552	5261	5416	5590	5501	5271	5499	
frequency difference	[]	Hz]	637	-	500	700	270	568	538	289	430	502	487	500	

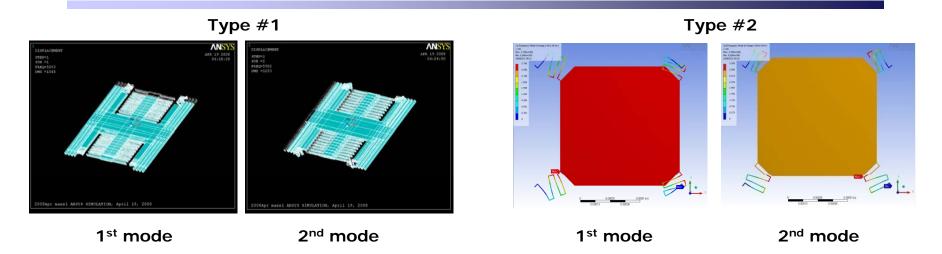
Project summary (cont'd)

ANSYS simulation result

	#	1	L	2	3	4		5	6	7	8	9	10
	type	#1	#2	#1	#1	#1	#1	#2	#1	#1	#1	#1	#1
1st mode frequency	[Hz]	5053	4512	5456	4970	5080	4963	4726	5268	5163	5025	4930	4980
2nd mode frequency		5502	5030	6043	5170	5360	5460	5223	5619	5621	5527	5510	5650
frequency difference	[Hz]	449	518	587	200	280	497	497	351	458	502	580	670

Measurement result

	#		1	2	3	4	Į.	5	6	7	8	9	10
	type	#1	#2	#1	#1	#1	#1	#2	#1	#1	#1	#1	#1
1st mode frequency	[Hz]	4500	4100	5020	5450	4520	4200	1	4385	4220	4880	4424	5030
2nd mode frequency	[Hz]	4970	4600	5550	5950	4560	4700	-	4903	4620	5380	4929	5530
frequency difference	[Hz]	470	500	530	500	40	500	-	518	400	500	505	500
distance/ voltage	[um/V]	0.033	0.033	0.067	0.033	0.027	0.120	-	0.076	0.053	0.008	0.112	0.080



• Comparison between Hand-calculated/ANSYS-simulated/Measured Result

	1st mode calculated frequency	2 nd mode calculated frequency	Calculated difference
Design #1	5749 Hz	5105 Hz	644 Hz
Design #2	-	-	-
	1st mode Simulated frequency	2nd mode Simulated frequency	Simulated difference
Design #1	5053 Hz	5502 Hz	451 Hz
Design #2	4512 Hz	5030 Hz	518 Hz
	1st mode measured frequency	2 nd mode measured frequency	Measured difference
Design #1	4500 Hz	4970 Hz	470 Hz
Design #2	4100 Hz	4600 Hz	500 Hz

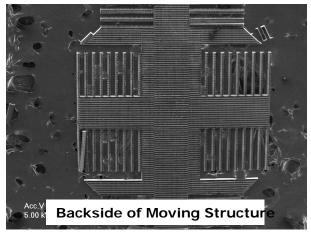


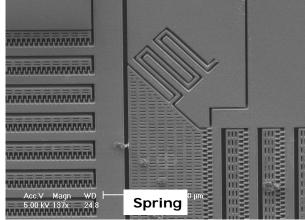
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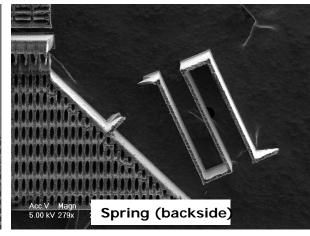
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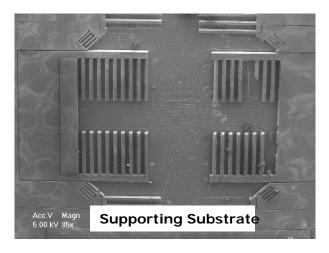
2008 Project review #1 (cont'd)

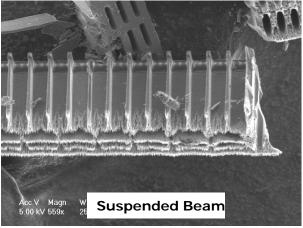
SEM image of Fabricated Results



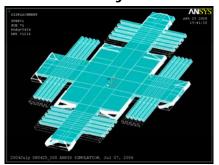


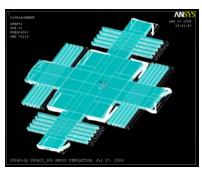


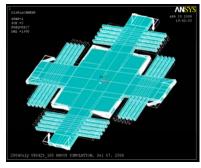


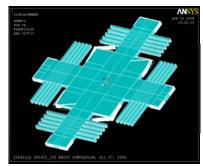


Modal Analysis Results









I st mode	2 nd mode
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3rd mode

4th mode

	1 st mode	2 nd mode	3 rd mode	4 th mode
Frequency (f)	5456 Hz	6043 Hz	8827 Hz	15264 Hz
Movement	y-axis	x-axis	Θ	Z-axis

• Comparison between Hand-calculated/Measured Result

Туре		Undercut	Mass	Resonant frequency	Stiffness	Driving voltage (displacement)
Design		0.3 μm	79 µg	X: 5.40 kHz Y: 5.80 kHz	X: 94.3 N/m Y: 112.3 N/m	70 V (4 μm)
	Device #1	0.4 μm	~74 µg	X: 5.02 kHz Y: 5.55 kHz	X: 73.6 N/m Y: 90.0 N/m	60 V (~4 μm)
Fabricated device	Device #2	0.4 μm	~74 µg	X: 4.40 kHz Y: 4.82 kHz	X: 56.5 N/m Y: 67.8 N/m	55 V (~4 μm)
	Device #3	0.4 μm	~74 µg	X: 4.85 kHz Y: 5.30 kHz	X: 68.7 N/m Y: 82.1 N/m	90 V (~4 μm)

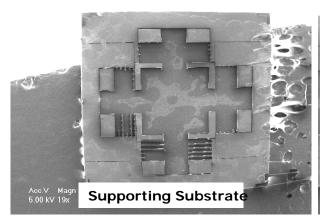


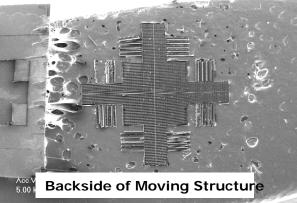
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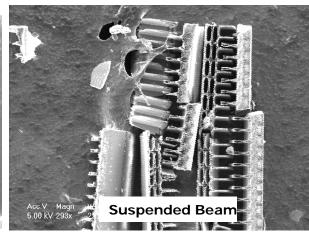
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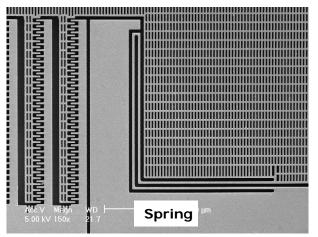
2008 Project review #2 (cont'd)

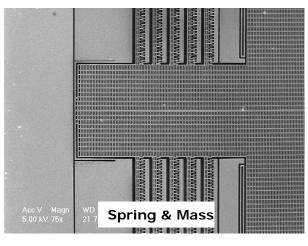
• SEM image of Fabricated Results





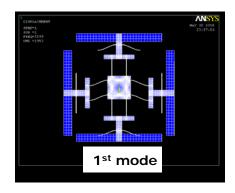


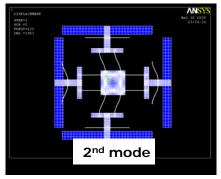


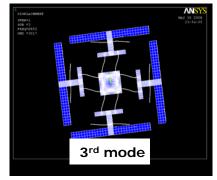


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Modal Analysis Results







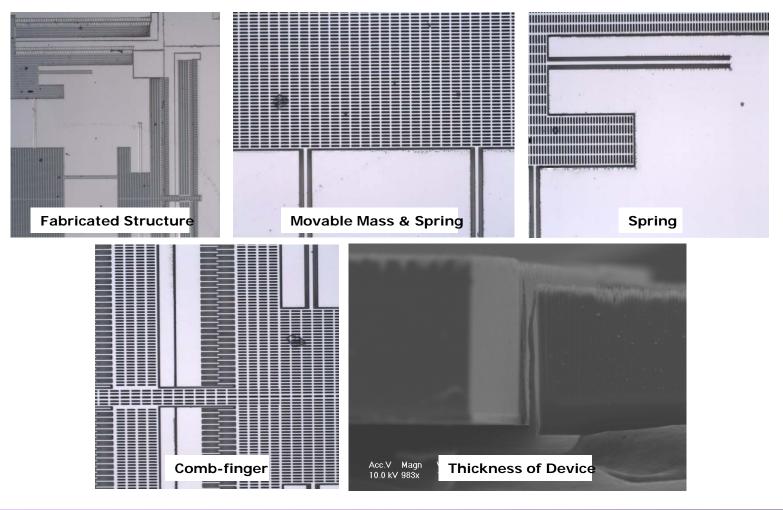
	1 st mode	2 nd mode	3 rd mode
frequency	5561 Hz	6087 Hz	8853 Hz

• Comparison between Hand-calculated/Measured Result

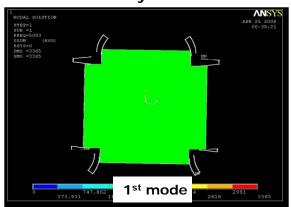
	design	fabricated	measured
Mass (kg)	2.47E-07	2.51E-07	-
spring constant_x (N/m)	39.36	45.76	-
spring constant_y (N/m)	32.8	38.15	-
frequency_x (Hz)	5679	6081	5950
frequency_y (Hz)	5184	5552	5450

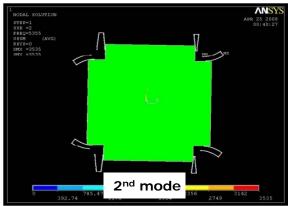
2008 Project review #3 (cont'd)

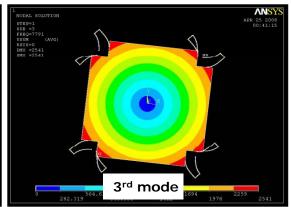
• SEM image/Microscope image of Fabricated Results



Modal Analysis Results







Mode	Resonant fre	quency [kHz]
Mode	Design	Simulation result
1st mode natural frequency	5.07	5.08
2 nd mode natural frequency	5.34	5.36
3 rd mode natural frequency	-	7.79

• Comparison between Hand-calculated/Measured Result

Parameters		Design Fabrication		Measurement
Mass		3.15e-7 kg	3.20e-7 kg	
k	k _x	354.00 N/m	238.81 N/m	
k	k _y	319.72 N/m	217.08 N/m	
£	f_x	5.34 kHz	4.35 kHz	4.56 kHz
I _r	f_y	5.07 kHz	4.16 kHz	4.52 kHz

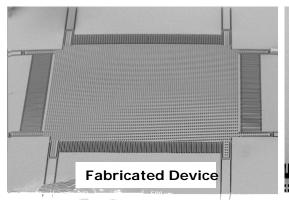


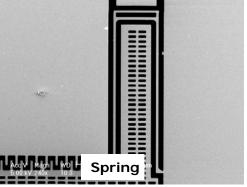
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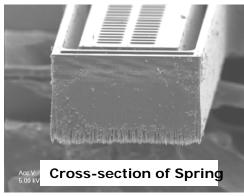
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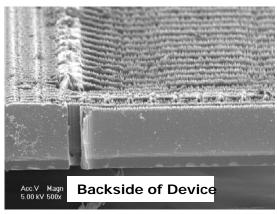
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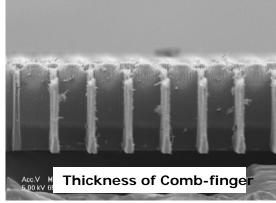
SEM image of Fabricated Results

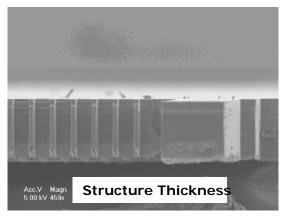




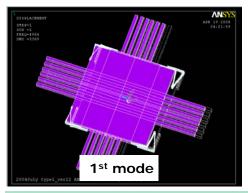


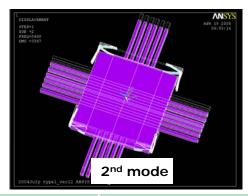


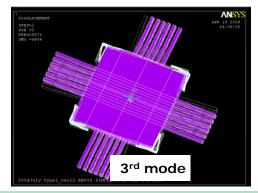




• Modal Analysis Results







Mode	Resonant frequency [kHz]		
Mode	Design	Simulation result	
1st mode natural frequency	4.95	4.963	
2 nd mode natural frequency	5.50	5.460	
3 rd mode natural frequency	-	8.070	

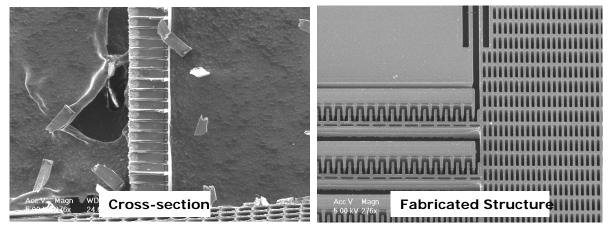
• Comparison between Hand-calculated/Measured Result

Par	ameters	Design	Fabrication	Measurement
	Mass	8.81e-8 kg	8.7e-8 kg	-
k	k _x	86.4 N/m	75.6 N/m	-
k	k _y	107.2 N/m	91.5 N/m	-
£	f_x	4.98 kHz	-	4.2 kHz
۱r	f_y	5.52 kHz	-	4.7 kHz



2008 Project review #5 (cont'd)

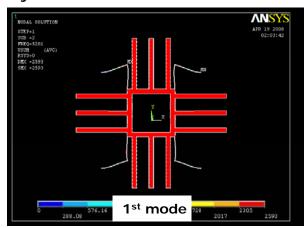
• SEM image of Fabricated Results

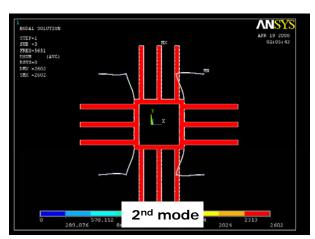


• Microscope image (resonance)



Modal Analysis Results





	Design	Simulation
Resonance frequency(y direction)	5.127 kHz	5268 kHz
Resonance frequency(x direction)	5.416 kHz	5619 kHz

• Comparison between Hand-calculated/Measured Result

	After Fabrication	Measurement result
Spring width	10 μm	9.283 μm
Thickness of spring	57.9 μm	54~57 μm
Thickness of mass	57.9 μm	56~58 μm
Resonance frequency(x direction)	5.619 kHz	4.702 ~ 5.130kHz
Resonance frequency(y direction)	5.268 kHz	4.240 ~ 4.605kHz



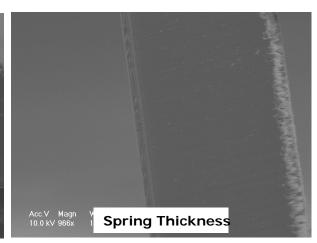
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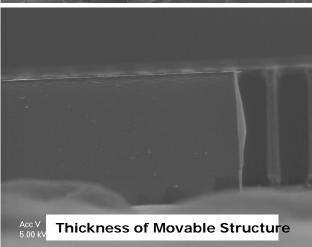
2008 Design review #6 (cont'd)

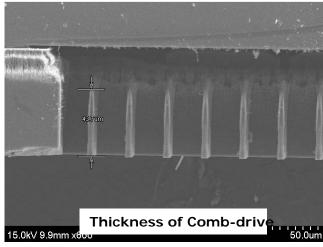
SEM image of Fabricated Results





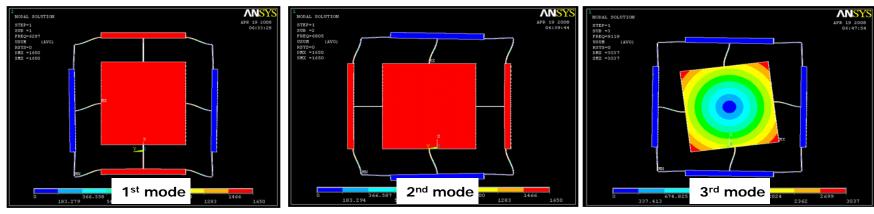






2008 Design review #7

Modal Analysis Results



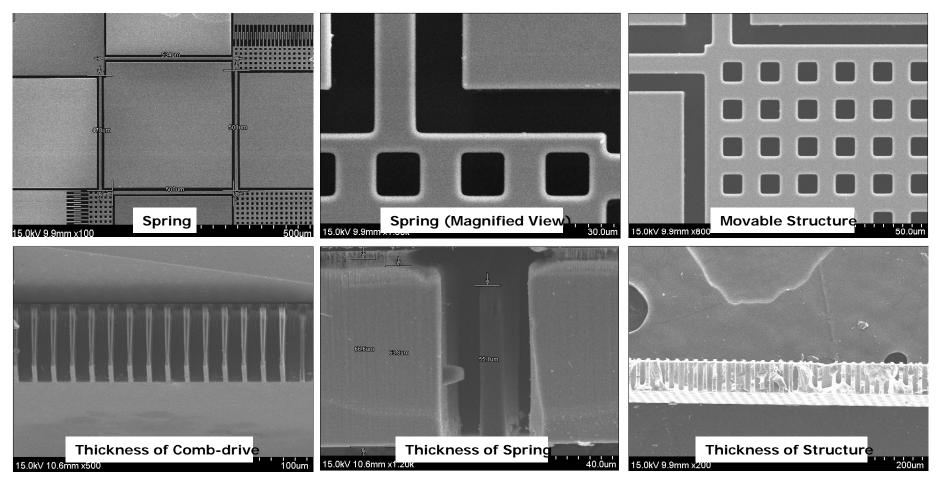
Target frequency	Calculation	Simulation
Y-axis resonant frequency	5.16 KHz	5.16 KHz
X-axis resonant frequency	5.59 KHz	5.62 KHz

• Comparison between Hand-calculated/Measured Result

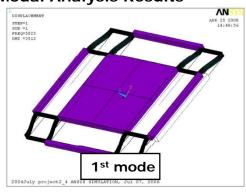
Parameter	Design[um]	Fabrication[um]
Mass thickness	65.0	60.0~61.0
Spring thickness	65.0	55.0~56.0
Comb thickness	65.0	52.0~55.0
Resonance frequency	5.59, 5.16 KHz	4.62, 4.22 KHz

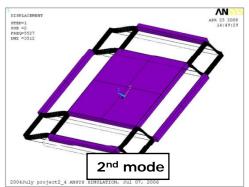
2008 Project review #7 (cont'd)

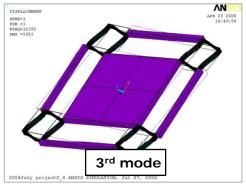
SEM image of Fabricated Results



Modal Analysis Results







	1 st mode	2 nd mode	3 rd mode	4 th mode
Simulation freq.	5.025 kHz	5.527 kHz	13.285 kHz	37.17 kHz
Target freq.	5 kHz	5.5 kHz	-	-
Movement	X-axis	Y-axis	Θ	-

Summarized Result

		Resonant freq.	DC+AC maximum actuation voltage	Actuation displacement
	Result	4.88 kHz	180 V	1.5 um
1 st mode	Expectation	5.025 kHz	182.7V	1 um
	error	0.145kHz (3%)	2.7V (1.5%)	50%
	Result	5.38 kHz	250V	2um
2 nd mode	Expectation	5.527 kHz	200V (25%)	2um
	error	0.147 kHz (2.7%)	50V (25%)	0%

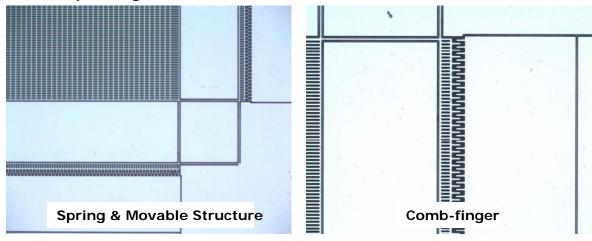


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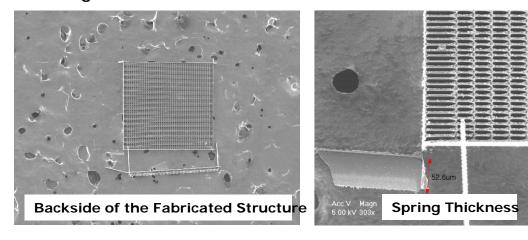
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2008 Project review #8 (cont'd)

Microscope image of Fabricated Results



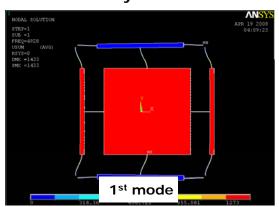
SEM image of Fabricated Results

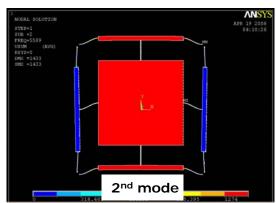


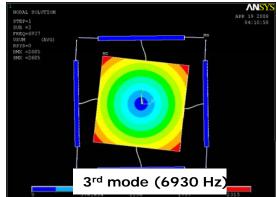


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Modal Analysis Results







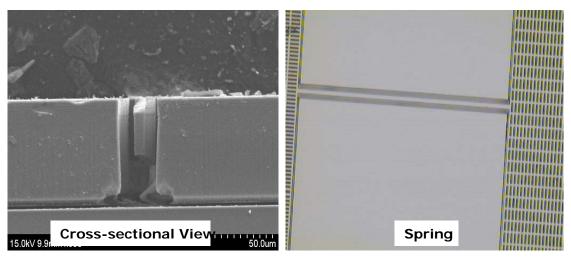
	Design	Simulation	Error(%)
Mass(kg)	3.723E-07	3.89E-07	4.5
f_{rx} (Hz): 1st mode	4784	4982	4.0
f _{ry} (Hz): 2 nd mode	5271	5509	4.3
Difference of resonant frequency(Hz)	487	527	7.5

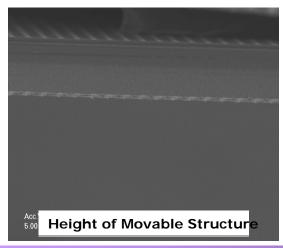
Summarized Result

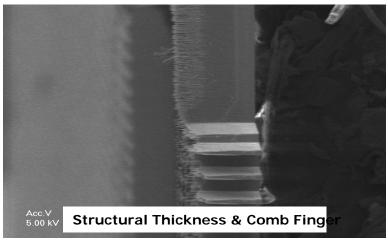
Device nu	umber	1	2	3	4	5	6	7	8	9	10
frequency	X axis	4890	4980	4950	5070	4910	4640	5060	4950	4950	4890
(Hz)	Y axis	4370	4480	4450	4570	4400	4140	4510	4440	4420	4360
differenc	e(Hz)	520	500	500	500	510	500	550	510	530	530

2008 Project review #9 (cont'd)

SEM image of Fabricated Results





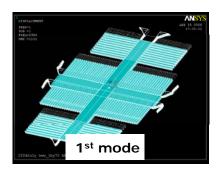


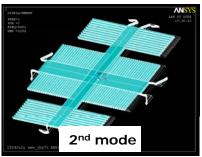


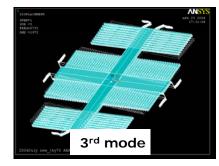
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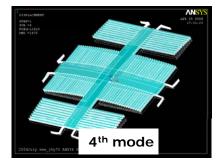
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Modal Analysis Results









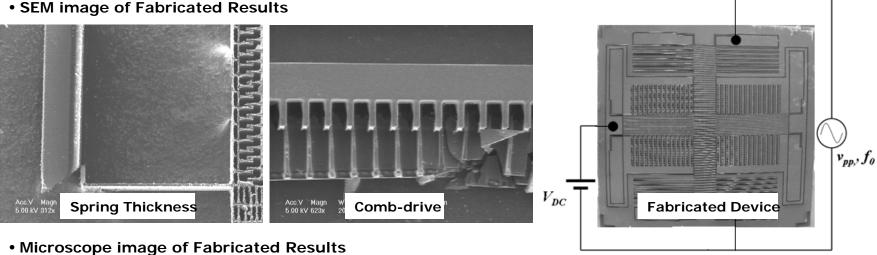
	1 st mode	2 nd mode	3 rd mode	4 th mode
Frequency (f)	4985 Hz	5652 Hz	8750 Hz	12410 Hz
Movement	y-axis	x-axis	Θ	Z-axis

Summarized Result

	Desi	gn	Fabrica	tion	
Mass (kg)	6.81	2-8	6.56e-8		
Stiffness (N/m)	77.62 64.74		79.13	65.72	
Resonance Frequency (k Hz)	5.50	5.01	5.59	5.07	

2008 Project review #10 (cont'd)











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